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Synthesis of single crystalline In_2O_3 octahedra for the selective detection of NO_2 and H_2 at trace levels

A facile method for synthesizing pure or metal decorated, single crystalline, indium oxide octahedra is demonstrated. While pure In_2O_3 shows outstanding sensitivity to nitrogen dioxide in the presence of ambient moisture, metal-loaded In_2O_3 is highly sensitive to hydrogen.

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Synthesis of single crystalline In_2O_3 octahedra for the selective detection of NO_2 and H_2 at trace levels†

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Single crystalline indium oxide (In_2O_3) octahedra have been synthesized by means of a vapor phase transport method at high temperature. The resulting material has been characterized by FE-SEM, HR-TEM, XRD, XPS and PL. The gas sensing properties of this material against oxidizing and reducing gases have been examined and the conditions for selectively detecting such gases have been established. A high response towards NO_2 has been obtained at a relatively low optimal operating temperature (*i.e.*, 130 °C) and even at room temperature. The fact that the response of the nanomaterial is more than two orders of magnitude higher for NO_2 than for H_2 , even in the presence of ambient moisture, makes it very promising for the selective detection of oxidizing species (at ppb levels) under real ambient conditions. The addition of noble metal nanoparticles (Pt and Pd) combined with an increase in the operating temperature (*i.e.*, 250 °C) significantly increases H_2 sensitivity and dramatically decreases the response to NO_2 . However, in this case, the presence of humidity negatively affects the response to H_2 . The sensing mechanisms are introduced and discussed.

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Introduction

Semiconductor metal oxides have become fascinating materials due to their application in numerous fields such as gas sensing, heterogeneous catalysis and solar cells among many others. Considering their application in gas sensing the presence of oxygen vacancies on the oxide surface plays an important role in the sensing mechanism.¹ In the case of n-type semiconductors, in the presence of oxidizing gases, for instance NO_2 , electrons are withdrawn from the conduction band, resulting in an increase in the resistivity of the metal oxide.² In contrast, when the metal oxide is in contact with a reducing species, such as H_2 , the gas reacts with the oxygen adsorbed at the surface of the material, resulting in a decrease in its electrical resistivity.^{3,4}

Nanostructured materials have attracted attention over the past few years, in an attempt to overcome some of the drawbacks

found when sensing gases employing bulk materials. Nano-materials show higher surface activity, superior responsiveness at lower operating temperatures (*i.e.* require lower power consumption) and superior long-term stability than their bulk counterparts. Among all metal oxide semiconductors, indium oxide (In_2O_3) is one of the most important n-type, wide direct band-gap (around 3.6 eV at room temperature) semiconductors due to its excellent electronic and optical properties. The concern for environmental protection, human health and green energy has led to an increasing number of publications for an efficient gas detection of different toxic and volatile gases using In_2O_3 nanostructure based sensors. Many morphologies have been reported, including nanowires,⁵ nanofibers,⁶ nanotubes,⁷ nanoparticles, nanosheets, and nano-flower like structures⁸ among many others. However, little has been reported about the sensing properties of other polyhedral morphologies such as cubes, hexahedra, octahedra and dodecahedra.⁹ The advantage of using morphologies like octahedra is that they possess sharp edges and tips, which provides more active sites and smooth surfaces and unique and perfectly defined crystalline facets (*i.e.* (111)) exposed to the gas atmosphere.

Also, there is a lack of information regarding gas sensing properties under humidity conditions in previous In_2O_3 studies. A summary of the gas sensing properties of nanostructured In_2O_3 synthesized employing different methods is shown in Table 1. According to what has been reported on the detection of hydrogen and nitrogen dioxide with In_2O_3 films, there is no

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Table 1 Gas sensing properties of nanostructured In_2O_3

| Synthesis method | Morphology | Target gas | Working temperature | Response | Ref. |
|------------------------------|-------------------|--------------------------------|---------------------|----------|-----------|
| Laser ablation | Nanowires | NO_2 (200 ppb) | Room temperature | -0.6^a | 14 |
| Thermal evaporation | Nanotowers | H_2 (2–1000 ppm) | 240 °C | $85\%^b$ | 15 |
| <i>In situ</i> oxidation | Nanoparticle | NO_2 (100 ppm) | 300 °C | 32^c | 16 |
| Sol-gel | Octahedra | NO_2 (100 ppm) | Room temperature | 40^c | 17 |
| AA-CVD | Thin film | NO_2 (80 ppb) | 400 °C | 2^c | 18 |
| Hydrothermal | Flower-like | NO_2 (200 ppb) | 140 °C | 40^c | 19 |
| Ammonolysis and re-oxidation | Octahedra strings | HCHO (100 ppm) | 420 °C | 1.8^d | 20 |
| CVD | Nanoneedles | H_2 (350 ppm) | 200 °C | 0.25^e | 21 |
| Ionic layer deposition | Thin film | H_2 (1000 ppm) | 450 °C | 8.5^d | 22 |
| Hydrothermal | Nanocubes | H_2 (5 ppm) | 150 °C | 25^d | 23 |
| Vapor phase transport | Octahedra | NO_2 (1 ppm)@50% R.H. | 130 °C | 120^c | This work |

^a Response calculated as $S = R_a/R_g - 1$. ^b Response calculated as $S = [(R_o - R_g)/R_o] \times 100$. ^c Response calculated as $S = R_g/R_o$. ^d Response calculated as $S = R_o/R_g$. ^e Response calculated as $S = 1 - R_a/R_g$.

clear pattern on the optimum operating temperatures for the detection of these two gases.

Even though pure metal oxide sensors can be very responsive to some gases, they often show poor selectivity. To overcome this drawback, noble metal particles can be added to the surface of the metal oxide active layer, improving their sensitivity towards a given target gas. Noble metals, such as Au,¹⁰ Pt¹⁰ or Pd,¹¹ are usually added to metal oxide nanostructures through a variety of methods, among which RF sputtering is one of the most commonly used. Its effectiveness has been demonstrated when used for functionalizing metal oxide nanomaterials.^{12,13}

Besides, In_2O_3 nanostructures show a strong photoluminescence (PL) emission in the visible range of the electromagnetic spectrum.²⁴ This broad emission located mainly at around 580 nm is thought to be originated from different kinds of defects present in the material. Among them, oxygen vacancies, oxygen interstitials, indium interstitials and oxygen antisite may be responsible for the broad emission observed by PL.^{25,26} These defects play a key role in the detection mechanism of semiconductor metal oxides. Therefore, PL studies can help to better understand the sensing mechanisms of indium oxide towards oxidizing and reducing agents.

In this work, we have synthesized In_2O_3 octahedra *via* vapor phase transport at high temperatures. The aim of the study is to shed light, for the first time, on the effect of the octahedral morphology on the gas sensing properties of In_2O_3 nanomaterials. Furthermore, it will be shown that the addition of Pt or Pd nanoparticles to the pure In_2O_3 octahedra can help tuning the gas sensing properties for the detection of hydrogen. PL measurements have been performed on sensors under *operando* conditions in the presence of air and NO_2 diluted in air flows, in order to further confirm the sensing mechanism of In_2O_3 octahedra.

Experimental

In_2O_3 octahedra were synthesized on top of Si/SiO₂ substrates *via* a vapor-phase transport method using a horizontal chemical vapor deposition (CVD) furnace. Si/SiO₂ substrates were previously cleaned by sonication. The cleaning process follows three steps of 5 minutes each in acetone, ethanol and deionized water,

and then dried in synthetic air. In a typical experimental procedure, 0.3 g of high purity In metal (99.99%) was placed on an alumina boat. Next to it, at a distance of around 1 cm the Si/SiO₂ wafer was placed. Then, the alumina boat with the precursor and the wafer were placed at the center of the horizontal furnace. The temperature was raised to 1000 °C at a rate of 15 °C min⁻¹, and kept constant for 120 min. The reaction took place in a dynamic Ar atmosphere (300 mL min⁻¹).

When the furnace was cooled down to room temperature, a pale green product was found on top of the Si/SiO₂ wafer. The crystalline phase and morphological structural features were studied by means of X-ray diffraction (XRD, Bruker-AXS D8-Discover diffractometer with parallel incident beam), a field emission scanning electron microscope (FESEM, Jeol 7600F), and high resolution transmission electron microscopy (TEM and HR-TEM, JEOL 2100). For TEM and HR-TEM analyses, a methanol dispersion of the sample was ultrasonicated for 20 minutes and a drop of it was deposited on a lacy carbon film supported by a nickel grid. For SEM analysis a product was scratched from the Si/SiO₂ substrate and placed on a carbon tape attached to an aluminum sample holder. Prior to the SEM investigation the sample was coated with a 3 nm thick carbon layer.

After that, the material was removed from the Si/SiO₂ substrate and mixed in a solution of 1,2-propanediol. The resultant ink was used to deposit the material by screen printing on top of an alumina substrate with interdigitated Pt electrodes. At the back side of such a substrate, a Pt heater was placed in order to perform gas tests at different temperatures. It is worth saying that in each CVD synthesis, a quantity of 5–8 mg of In_2O_3 octahedra is obtained, and this is enough for producing 1–2 sensors.

After the screen printing deposition of the nanomaterial, a 6 µm thick layer is obtained on top of the alumina substrate. A SEM micrograph (cross-sectional view) can be found in the ESI.†

In order to deposit Pt or Pd nanoparticles on In_2O_3 sensors, an RF sputtering system was used. For Pt, 30 W and 8 s were used for the deposition and, for Pd, 50 W and 8 s were used, both under 3.75 mTorr and at room temperature. This process was conducted as a second step after the screen-printing of pure In_2O_3 . The sputtering process parameters had been optimized



previously for obtaining small and well-dispersed Pt or Pd nanoparticles, avoiding coalescence of the nanoparticles. It is not realistic to vary these parameters in view of altering Pd or Pt loading, as it is not the only variable that changes, particle size changes as well. It has been shown previously that sensing performance in Pd/SnO₂ samples improves with decreasing Pd particle size.²⁷ The amount of metal loading employed in the In₂O₃ sensors was guided by the results showing that reducing the amount of metal sputtered reduced the size of metal nanoparticles.

The chemical characterization of the active layers was performed using X-ray photoelectron spectroscopy (XPS); the XPS analysis was carried out using a Physical Electronics, VERSAPROBE PHI 5000 spectrometer equipped with monochromatic AlK α radiation with 0.7 eV energy resolution and a dual-beam charge-compensation system. All the XPS data were elaborated using Casa XPS v.2.3 software and binding energies were referenced with respect to the C 1s peak at 284.5 eV.

For obtaining the PL spectra, a He-Cd laser at 325 nm was used in order to overcome the band gap barrier of the In₂O₃ nanomaterial. The luminescence was dispersed using an Oriel Instruments 74 000 monochromator and detected using a Hamamatsu H8259-02 with a socket assembly E717-500 photomultiplier. All sources of noise were removed using a Stanford Research System SR830 DSP lock-in amplifier.²⁸ Sensors were hosted in a specially designed chamber fitted with a UV-quality quartz window, which allowed us to run PL measurements in the presence of either dry air or nitrogen dioxide diluted in air.

Results and discussion

In₂O₃ nanostructures were synthesized *via* a vapor-solid mechanism, as indicated by the absence of the metal catalyst on the substrate. After melting of In grains, In vapor reacts with residual oxygen present in the furnace, thus forming oxidized clusters. When the temperature further increases, the oxidized In clusters act as nucleation centers for the formation of In₂O₃ crystals. The formation of In₂O₃ nuclei will lead to the formation of In₂O₃ with the desired morphology depending on the reaction temperature.^{29,30} At 700 °C, In₂O₃ triangular crystals are formed whereas at 800–1000 °C pyramids and octahedra can be obtained. The facets exposed correspond to the most energetically stable atomic planes in the lattice. Fig. 1 shows FESEM images of the In₂O₃ octahedra synthesized at 1000 °C. As shown, the final product consists of a high density of octahedral shaped structures (Fig. 1, upper panel). No other morphologies are observed, which indicates the uniformity of the process. A regular octahedron is composed of eight equilateral triangles, four of which meet at the same vertex. The side of each triangle is about 500 nm and all the faces are almost perfectly smooth and without any visible structural defects (Fig. 1, lower panel). Moreover, these structures possess sharp edges and vertexes.

Further characterization has been carried out using TEM and HRTEM. Fig. 2 shows TEM and HRTEM images of the In₂O₃ octahedra. As observed, the side length of the octahedron

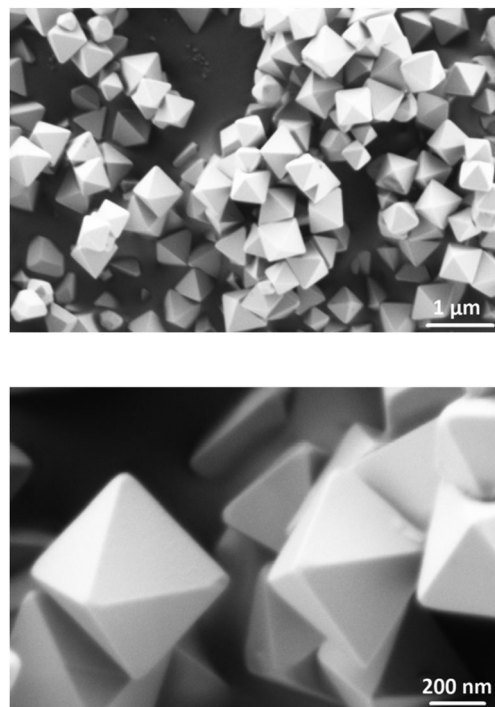


Fig. 1 Low and high magnification ESEM images of the In₂O₃ octahedra.

is about 500 nm, which is consistent with that observed in the FESEM images. The inset of Fig. 2 exhibits a HRTEM image of the edge of the octahedron. It clearly exhibits the continuous lattice fringes of the structures, showing the crystalline nature of the In₂O₃ octahedra. The distance measured between two adjacent fringes is 0.29 nm, which corresponds to the {111} interplanar distance of the cubic phase of In₂O₃ according to ICDD card no. 01-071-2194.

EDS carried out in an area of several In₂O₃ octahedra confirms that there are no impurities present as no other peaks other than those of indium and oxygen could be found (Fig. S2, ESI†).

Next, characterization of the sputtering-deposited Pt and Pd nanoparticles on top of the In₂O₃ octahedra was carried out. HR-TEM images of the Pt and Pd nanoparticles are shown in Fig. 3 and 4 respectively. As shown, after the deposition of Pt or

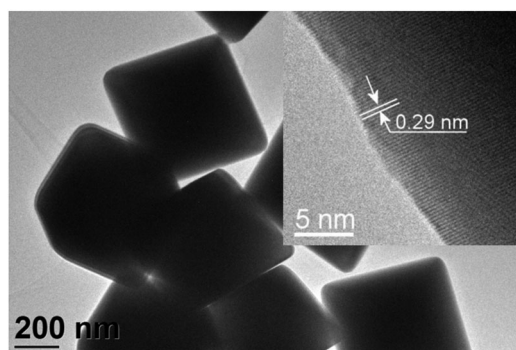


Fig. 2 TEM and HRTEM (inset) of the In₂O₃ octahedra.



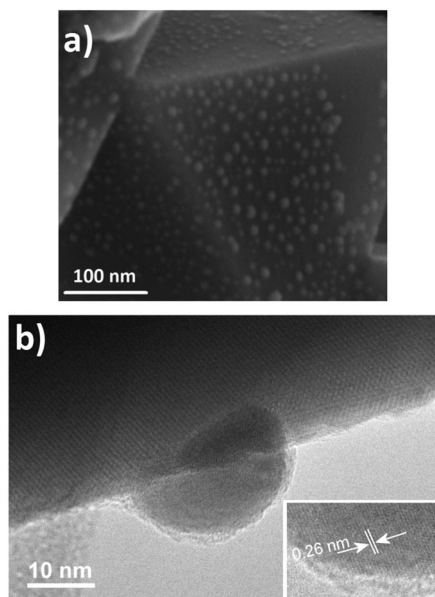


Fig. 3 (a) FESEM image of the Pt/In₂O₃ octahedra, and (b) HR-TEM image of a Pt nanoparticle attached to an In₂O₃ octahedron. The inset shows the interlayer distance of the Pt nanoparticle.

Pd nanoparticles, the octahedral morphology was preserved. Furthermore, Pt nanoparticles appear to be homogeneously distributed on the faces of the octahedra. The size of such nanoparticles is about 10–20 nm, as shown in Fig. 3. Closer inspection reveals that the measured interlayer distance is 0.26 nm thus corresponding to the {111} interplanar spacing of PtO according to ICDD card no. 43-1100.

By analyzing the Pd decorated samples we can observe that the Pd nanoparticles are also homogeneously distributed along the faces of the In₂O₃ octahedra. In contrast to the nanoparticles sputtered with a Pt target, these nanoparticles appear to be smaller, as their size ranges between 8 and 10 nm. Such nanoparticles have an interplanar spacing of 0.259 and 0.263 nm. Such lattice parameters are close to the interplanar spacing of tetragonal PdO ($d_{111} = 0.263$ nm and $d_{002} = 0.266$ nm according to ICDD card no 01-085-0624). In addition, according to Kibis *et al.*³¹ these values are characteristic of highly oxidized palladium nanoparticles where palladium is mainly in the +2 oxidation state.

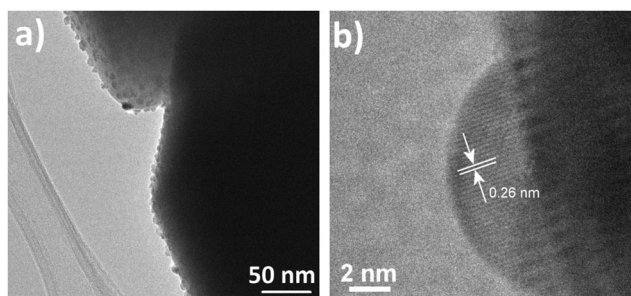


Fig. 4 (a) HR-TEM image of the Pd/In₂O₃ octahedra, and (b) HR-TEM image of a single Pd nanoparticle attached to an In₂O₃ octahedron.

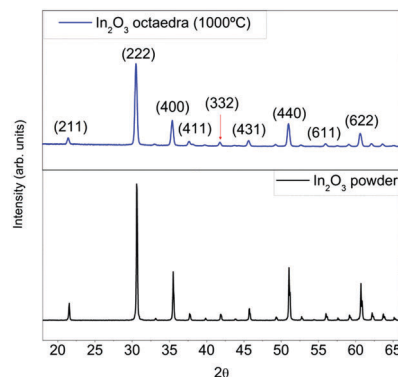


Fig. 5 XRD patterns of the pure In₂O₃ octahedra (top) and a commercial In₂O₃ powder (bottom).

The crystalline phase was confirmed by means of X-ray diffraction (XRD). As shown in Fig. 5, pure samples show the typical features of cubic In₂O₃. No peaks belonging to other materials or impurities could be found.

Additional XRD measurements for Pt and Pd-doped In₂O₃ samples were performed (Fig. S3, ESI†). These results confirm that metal decoration does not affect the crystallinity of In₂O₃ octahedra, which retain the cubic phase. Due to the low amount of metal loading, no peaks arising from Pt or Pd could be found. This is often the case for the typical amounts of metal loading used in gas sensing applications.^{20,32}

With the aim to identify the chemical state of elements in the indium oxide and in the catalyst particles (Pt, Pd), XPS analysis was carried out on the nanostructures deposited on the sensor substrates. The In 3d core level spectra of both samples are shown in Fig. S5 of the ESI†. These are composed of two components, relative to the spin-orbit doublets (3d_{5/2} and 3d_{3/2}), respectively, at 444.2 eV and 451.8 eV indicating that In is mainly found in the +3 oxidation state, which almost corresponds to the stoichiometric state.³³ The O 1s XP spectra are comprised of two intense peaks centered at 529.8 eV and 531.8 eV (Fig. 6). The more intense peak has been ascribed to oxygen bonds in In–O–In, while the high binding energy peak at 531.2 eV is possibly partially related to oxygen vacancies in the bulk of metal oxides.³⁴

By inspecting the Pt 4f XP spectrum we observe two doublets (Fig. 7), one with the 4f_{7/2} component at 71.2 eV and the other at 72.5 eV. The existence of these two doublets suggests the presence of a core-shell structure with the low-binding energy doublet assigned to photoelectrons emitted from Pt atoms in the core of the particles, while the high-energy component is assigned to an oxidized shell. Assignment to a particular platinum oxide is complex as several intermediate oxidation states between PtO and PtO₂ have been reported to have peak positions in the range between PtO at 71.3 eV and PtO₂ at 74.1 eV.³⁵

Conversely, in Fig. 7(b) the Pd 3d_{5/2} component at 336.2 eV clearly indicates the formation of PdO while the Pd 3d_{5/2} component at 335.1 eV indicates the presence of Pd⁰.³⁶ Due to the small amount of Pt and Pd atoms deposited on the sample surface, the signal generated by photoelectrons emitted



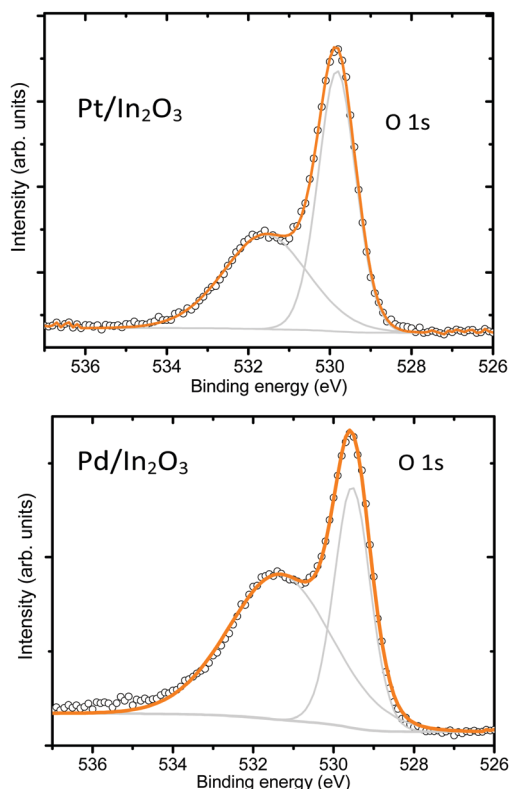


Fig. 6 O 1s core level XP spectra of Pt/In₂O₃ and Pd/In₂O₃.

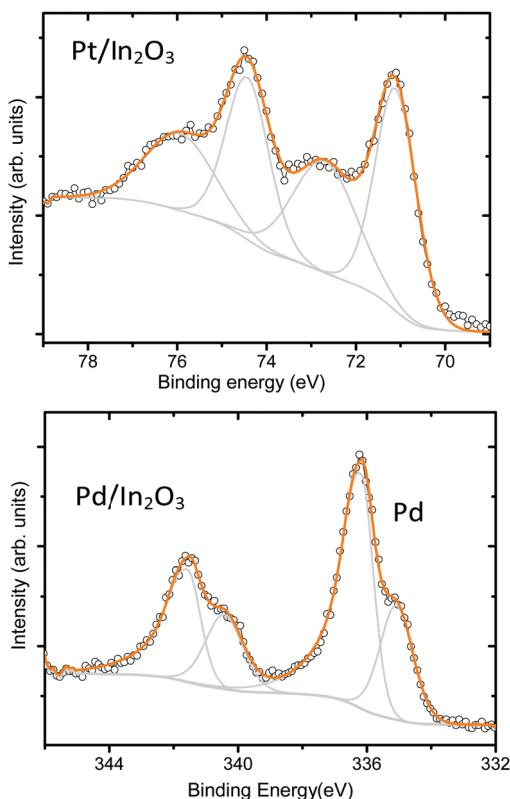


Fig. 7 XP spectrum of Pt (4f) and Pd (3d).

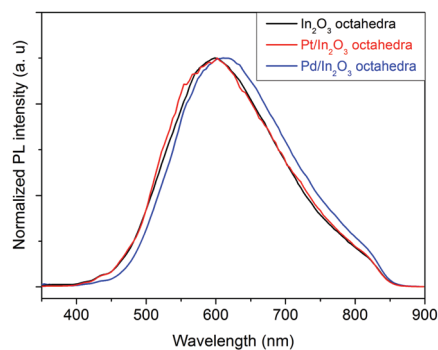


Fig. 8 PL spectra of the three sensors under dry air conditions.

from oxygen atoms bound to Pt appears in the background of the O 1s peak. If we compare the XPS results recorded on the metal decorated samples with the ones recorded on the pristine In₂O₃ samples (shown in Fig. S4 in the ESI†), we observe that the decoration with metal nanoparticles has no influence in the oxidation state of the In₂O₃ octahedra.

Furthermore, *in situ* PL experiments under air conditions have been performed on sensors employing pristine In₂O₃, Pt or Pd decorated In₂O₃ octahedra. PL spectra were obtained for sensors operated at 130 °C in a flow of dry air.

Fig. 8 shows the normalized photoluminescence spectra of different indium oxide sensors operated at 130 °C in dry air. As one can observe, for the pristine In₂O₃ and the Pt decorated In₂O₃ octahedra, there is a strong PL emission at 600 nm whereas for the Pd decorated In₂O₃ octahedra, the strong emission occurs at 610 nm. This indicates that similar types of defects are present in the three samples. Such an orange emission band is thought to have its origin in deep In interstitials present in the nanomaterial.²⁵

Finally, the In₂O₃ octahedra samples were subjected to gas sensing tests using oxidizing (NO₂) and reducing (H₂) gases by means of DC resistance measurements performed at different operating temperatures (100–250 °C). All sensors were exposed to 15 minutes of a given concentration of a species, followed by a 30 minute cleaning phase in dry air. All sensors showed an increase or decrease in resistance under exposure to oxidizing or reducing gases, respectively. This implies that In₂O₃ behaves as an n-type semiconductor.

The typical response and recovery cycles of an In₂O₃ octahedra sensor toward increasing concentrations of NO₂ in dry air at 130 °C are presented in Fig. 9(a). It is well known that NO₂ is a very oxidizing gas and can be easily adsorbed on In₂O₃ structures, which leads to a decrease of the electron density of In₂O₃ and thus, a decrease in conductance.

The response and recovery time for all the concentrations is around 200 and 300 s, respectively, which is in the range of the response and recovery time of other studies of the In₂O₃ material.^{37,38} Furthermore, the baseline resistance can be recovered after exposing the sensor to dry air, which shows that the sensor is completely reversible. Also, it is seen that the signal to noise ratio is excellent. Fig. 9(b) shows the dependence of the In₂O₃ octahedra sensor as a function of different



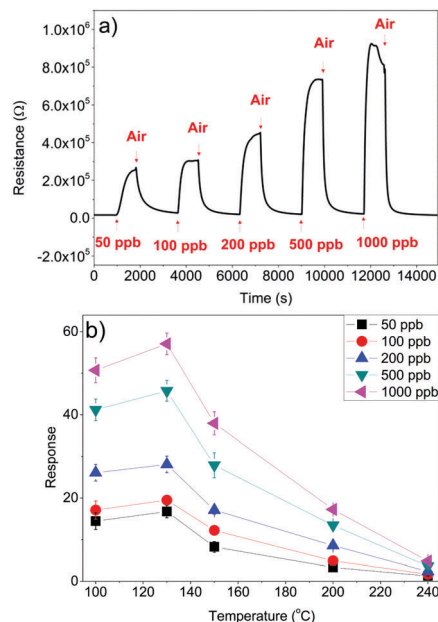


Fig. 9 (a) Response of the In₂O₃ octahedra sensor at 130 °C and (b) performance of the sensor as a function of temperature.

concentrations of NO₂ as a function of different operating temperatures.

As shown in Fig. 9(b), sensors work optimum when operated at a relatively low temperature of 130 °C. Comparing these results with those available in the literature for similar In₂O₃ structures, Mu *et al.*¹⁷ reported a response that is 4 times lower with very slow response and recovery dynamics at room temperature for 100 ppb NO₂. Bloor *et al.*¹⁸ reported a response that is 8 times lower at a much higher operating temperature (*i.e.* 400 °C). If we keep increasing the temperature, the performance sensors clearly worsen.

Moreover, gas sensing tests on low concentrations of NO₂ at room temperature have been performed. As shown in Fig. S6 of the ESI,[†] the sensor achieves a response of $R_{\text{gas}}/R_{\text{air}} = 2.46$ when exposed to 200 ppb of NO₂ in air. This shows that our nanomaterials have potential for detecting oxidizing species even when operated at room temperature.

It is important to note that our sensors are able to detect NO₂ in the range of ppb with an excellent signal to noise ratio, which means that it is possible to detect even lower concentrations of this gas (the theoretical limit of detection can be estimated at units of ppb). A correlation between the logarithm of the sensor response and the concentration was easily obtained and it is shown in Fig. 10(a). As observed, a linear fit can be obtained from the response as a function of the concentration of NO₂, with an *r*-square of nearly 0.99 in all the cases.

Furthermore gas sensing performance of an In₂O₃ octahedra sensor under humid conditions was examined by exposing it to NO₂(g) in a background of air at 50% relative humidity (at 22 °C) and the response was compared to that under dry conditions. The sensitivity towards NO₂ (the slope of the red curve in Fig. 10(b)) under humid conditions is significantly higher than that under dry conditions (the slope of the black curve in Fig. 10(b)).

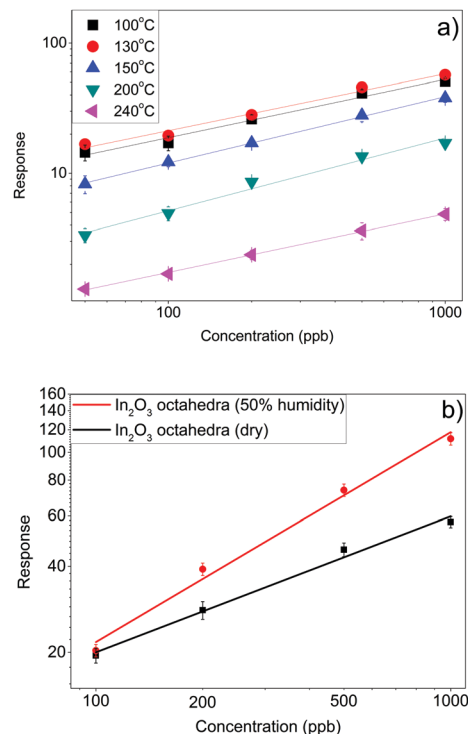


Fig. 10 (a) Response of the In₂O₃ octahedra sensor as a function of NO₂ concentration and (b) performance of the sensor at 130 °C under humid conditions (50% R.H. at 22 °C).

Comparing the performance of the In₂O₃ octahedra sensors with that of sensors employing a commercially available In₂O₃ nanopowder (Sigma-Aldrich, 632317), it is observed that our nanomaterial shows a higher response under optimum working conditions, *i.e.* 130 °C, as shown in Fig. S7 of the ESI.[†]

Also, the performance of Pt and Pd-doped In₂O₃ octahedra sensors was examined under dry conditions. The responses obtained were extremely low compared to the response of pure In₂O₃ octahedra sensors under the optimum working conditions as presented in Table S2 of the ESI.[†]

Additionally, *in situ* PL experiments on the sensors under 100 ppm of NO₂ target gas have been performed at 130 °C.

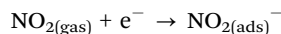
Fig. S8 of the ESI[†] shows the PL spectra of different indium oxide sensors operated at 130 °C in the presence of 100 ppm of NO₂ in air. In this case, the strong PL emission is located at 600 nm for the three samples. This also suggests that the defects responsible for this emission are In interstitials.

As one can see, there is no significant difference between the normalized spectra under dry air shown in Fig. 8 and under NO₂ concentration. This implies that there is no change in the concentration of In interstitials on the nanomaterial upon interaction with nitrogen dioxide. Also, the change in the number of oxygen vacancies caused by the presence of NO₂ does not substantially modify the PL.

The sensing mechanism of semiconductor materials consists of two steps: the first one is the receptor function which involves the recognition of the species through gas–solid interaction, and the second one is the transduction function which

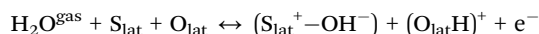


involves the change in the electrical resistance of the sensor.¹³ At low operating temperatures (*i.e.*, lower than 130 °C), when In₂O₃ octahedra are exposed to NO₂(g), the gas becomes ionosorbed on the surface of the material due to its high electrophilic properties, resulting in an increase of the overall resistance of the sensor:

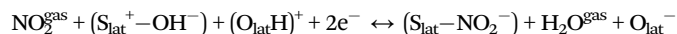


The rapid decrease in the response of the sensor at temperatures higher than 130 °C can be explained by the decreasing number of active sites for the adsorption of NO₂ molecules. At higher temperatures, the amount of oxygen molecules adsorbed is greatly increased and as a consequence, the number of free active sites suitable for the adsorption of NO₂ molecules is reduced. Therefore, the response of the sensor is sharply decreased. The presence of Pt or Pd nanoparticles on the surface of In₂O₃ favors, *via* a chemical sensitization, the increase in the number of adsorbed oxygen species at the surface of the metal oxide.¹³ This, once more, significantly reduces the number of active sites for the adsorption of NO₂ and explains the dramatically reduced NO₂ response observed for metal decorated samples.

Regarding the measurements under humid conditions shown in Fig. 9(b), at moderate operating temperatures (*i.e.* ≤ 200 °C), the interaction of ambient moisture with different metal oxide surfaces can be summarized as follows. The interaction with water vapor results in an increase of bridging hydroxyls and the formation of terminal hydroxyl groups.^{39,40} Also, dissociative adsorption of water takes place on surface metal atoms (S_{lat}) giving rise to terminal OH groups. Assuming the dissociation of water molecules, hydroxyl surface groups are formed:



In addition to the ionosorption of NO₂ on the surface of the metal oxide, the following interaction mechanism might be possible between NO₂ and the terminal hydroxyl groups:⁴¹



As a consequence, additional electrons are trapped *via* the conduction band of the metal oxide material, leading to an increase in NO₂ response under humid air conditions.

Furthermore, the gas sensing properties of the In₂O₃ octahedra against a reducing gas such as H₂ were investigated. The experiments were performed under the same conditions as those previously described for NO₂. Fig. 11(a) shows the response of a sensor to low concentrations of H₂ at 200 °C. The sensor resistance decreases with increasing H₂ concentration, which is in agreement with the behavior of an n-type semiconductor exposed to a reducing gas. As in the case of NO₂ sensing, the signal to noise ratio is excellent for H₂ sensing, and the sensor will be able to detect concentrations in the ppb range (the theoretical limit of detection for hydrogen is in the tens of ppb range).

In contrast to NO₂ sensing, the optimal operating temperature is higher for H₂ sensing. The best performance of the sensor is found at the highest examined temperature of 250 °C (Fig. 11(b)).

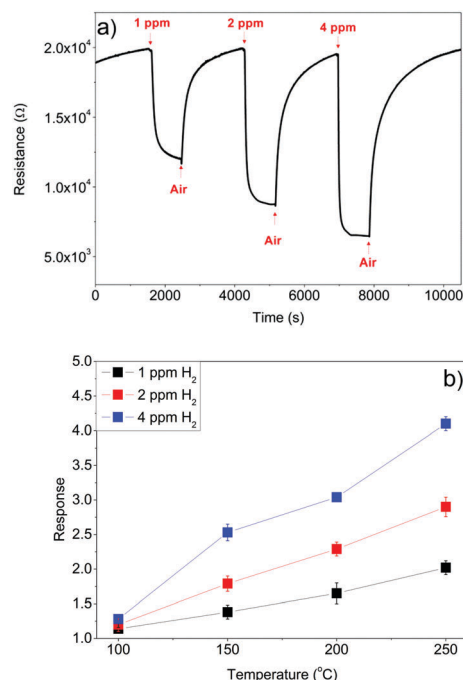


Fig. 11 (a) Response of the In₂O₃ octahedra sensor to different concentrations of H₂ at 200 °C, and (b) response of the sensor as a function of the temperature.

This suggests that we can make the sensor more selective to a target gas by properly choosing an operating temperature; low temperatures (*e.g.* 130 °C) will be optimal for NO₂ detection, while higher temperatures (*e.g.* 250 °C) are suited for H₂ detection. When operated at 130 °C and in a humid background, the sensor is very selective to selective oxidizing species because its response to 1 ppm NO₂ is more than two orders of magnitude higher than its response to 1 ppm H₂. When operated at 250 °C, the sensor becomes responsive to hydrogen. However, its response to nitrogen dioxide, although significantly decreases, remains of the same order of magnitude as that of hydrogen.

A possible approach to increase the sensitivity of In₂O₃ octahedra sensors to reducing gases like H₂ is to load In₂O₃ with different noble metal nanoparticles. In this work, Pt and Pd nanoparticles have been chosen because they are well-known sensitizers for hydrogen detection in metal oxides.^{20,42}

The lack of complete baseline recovery in both cases (worsens if the operating temperature is lowered) implies that the dynamics of sensor recovery is lower for H₂ than for NO₂ (Fig. 12).

Fig. 13 shows the comparison between pure In₂O₃ octahedra and Pt/Pd-doped In₂O₃ octahedra for H₂ sensing. Both dopants improve the sensing characteristics of pure In₂O₃ octahedra. Particularly, it is easily observed that the best response in terms of H₂ sensing is achieved with the Pt-doped In₂O₃ octahedra with the optimum temperature of 200 °C, lower than that of pure In₂O₃ octahedra. Recalling that metal loading resulted in a very significant decrease in sensitivity to nitrogen dioxide (see ESI†), Pt loading, in contrast, facilitates the selective detection of H₂.



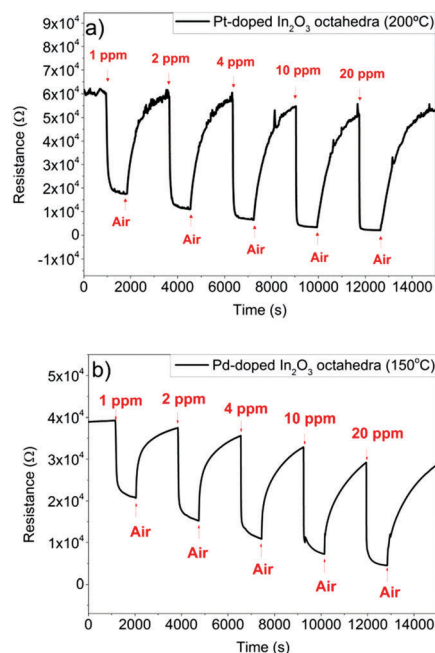


Fig. 12 (a) Response of the Pt-doped In₂O₃ octahedra sensor to different concentrations of H₂ at 200 °C, and (b) response of the Pd-doped In₂O₃ octahedra to different concentrations of H₂ at 150 °C.

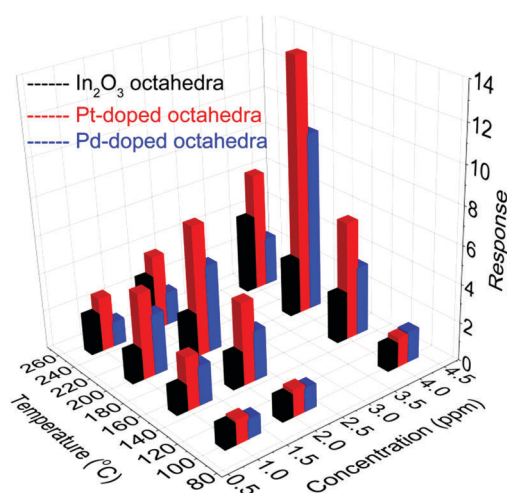


Fig. 13 Performance of the undoped and Pt/Pd-doped In₂O₃ octahedra sensors as a function of the operating temperature for H₂.

Moreover, the performance of Pt-doped In₂O₃ sensors operating in a humid background has been tested. The sensors operated at 200 °C were exposed to different concentrations of H₂ gas (1, 2, 4, 10 and 20 ppm) in a background of air at 50% relative humidity (at 22 °C) as shown in Fig. 14. The sensor under 50% humidity shows significantly lower sensitivity (0.44 ppm⁻¹) than the sensor under dry conditions (0.72 ppm⁻¹).

Also, the response to H₂ at 250 °C of Pt-In₂O₃ octahedra sensors is one order of magnitude higher than that of the same sensors to NO₂ gas, as can be deduced from Table S1 in the ESI.† In other words, sensors become selective to reducing species (e.g. H₂) by increasing the operating temperature

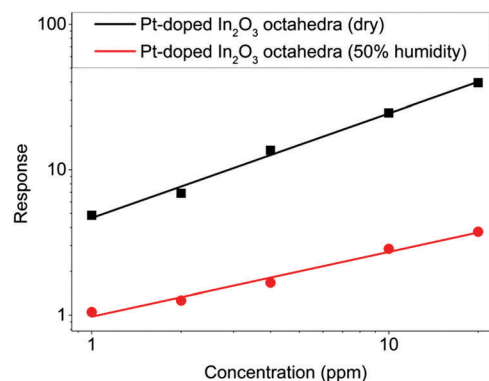
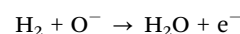


Fig. 14 Comparison between the responses of the Pt-doped sensor under dry and humid conditions at 200 °C.

and decorating the material with noble metal nanoparticles such as Pt.

It is generally accepted that reducing gases change surface conductivity due to a change in the oxidation state of the material. The fact that there is a sharp decrease in the response of the Pt-doped In₂O₃ sensor when exposed to H₂ gas with 50% of relative humidity can be explained as follows: at relatively low temperatures, vapors of both H₂ and H₂O interact in the same way with the surface of the material, creating new OH groups and consuming the bridging oxygen atoms. As a consequence, the combined interaction of hydrogen and water vapors with the surface becomes competitive.³⁹ Therefore, the response of the sensor is greatly decreased as shown in Fig. 14.

As previously stated, the sensing mechanism of n-type sensors is based on the variation of the electrical resistance of the sensing element, which depends basically on the gas atmosphere, the operating temperature and morphology of the sensing material among other factors. When the sensor is exposed to dry air, oxygen molecules adsorb on the surface of the material, capturing electrons of the conduction band. This creates a depletion layer derived from the adsorbed oxygen. As H₂ is introduced in the measurement cell, H₂ molecules react with the chemisorbed oxygen, releasing an electron back to the semiconductor, and thus, reducing the resistance of the sensor:³⁹



However, we have experimentally seen that modifying the bare oxide with noble metal nanoparticles greatly enhances the response towards reducing gases. In this case, the gas–solid interaction that involves the receptor function is the catalytic oxidation of the target gas over the grain surface. When H₂ molecules are in contact with the metal nanoparticles, they dissociate into H atoms that can spill-over to the semiconductor surface to react with the adsorbed oxygen. Therefore, the addition of the metal nanoparticle favors the reaction of the target gas with the semiconductor oxide *via* catalytic oxidation (chemical sensitization). In that way, the metal additive facilitates the interaction between the gas species and the semiconductor oxide. This type of interaction occurs mainly in the Pt-doped sensors.¹³



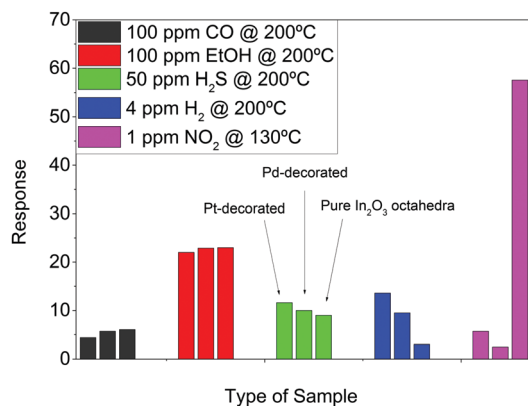


Fig. 15 Comparison between the responses of the Pt-doped, Pd-doped and pure In₂O₃ octahedra to several gases. Each colour represents a different gas. For each set of columns, the left one represents Pt-decorated In₂O₃ octahedra, the middle one represents Pd-decorated In₂O₃ octahedra and the right one represents pure In₂O₃ octahedra.

In a different mechanism, the metal additive in the oxidized state acts as a strong electron acceptor from the oxide creating a space charge layer. Then, the additive is reduced when it makes contact with the target gas; it relaxes the space charge layer by giving back the electrons to the semiconductor oxide. This type of interaction is named electronic sensitization and it occurs with noble metals like Pd. When Pd is exposed to dry air, it forms a stable metal oxide (PdO) that interacts with the In₂O₃ octahedra. When in contact with H₂, they are converted back to the metallic state (Pd) resulting in the disappearance of the electronic interaction with In₂O₃.⁴² The results of the XPS analysis performed over the samples and shown in Fig. 7 confirm the presence of PtO and PdO on our sensors.

The reason why the response of the Pd-doped sensor is lower than the response of the Pt-doped one might be that the behaviour of the latter is a combination of the chemical sensitization and the electronic sensitization stated above.

In addition to the above-discussed chemical and electronic sensitization mechanisms, sensor response is also influenced by the amount of metal loading. However, the sputtering process was conducted in order to obtain nanoparticles with near to optimal sizes, according to previous studies.^{27,42}

To further study the selectivity, all sensors were exposed to CO, EtOH, H₂S, H₂ and NO₂, as shown in Fig. 15.

In Fig. 15, one can see the response of the three types of materials exposed to several gases/vapors under their optimum working conditions. As observed, the best response is obtained for the pure In₂O₃ octahedra exposed to NO₂ at a relatively low temperature (130 °C). Furthermore, a good response to ethanol vapors is also observed. However, the sensing temperature is much higher than that for NO₂ and the concentration is two orders of magnitude higher.

If we focus only on the reducing species, we can see that at the same working temperature (200 °C), Pt-decorated sensors are able to detect 4 ppm of H₂ with a good response, if we take into account that hydrogen concentration is nearly two orders of magnitude lower than that of EtOH, CO and H₂S.

Conclusions

We have developed a facile method to synthesize high crystalline In₂O₃ octahedra at high temperatures, whose face size is around 500 nm. Furthermore, an easy way to decorate such nanostructures with noble metal nanoparticles has been shown. XPS measurements have shown that the metal nanoparticles have a core-shell structure in which the core of the particle corresponds to the metal and the shell corresponds to the oxidized metal.

Additionally, we can say that pure In₂O₃ octahedra are excellent for detecting NO₂ gas with outstanding sensitivity (0.43 ppb⁻¹) at low temperatures (130 °C), while the response to H₂ remains two orders of magnitude lower under the same conditions. In addition, the presence of humidity increases the sensitivity to NO₂ and, at the same time, reduces the response to H₂, which results in increased selectivity. This makes our sensor an excellent candidate to detect, in a selective way, oxidizing gases such as NO₂ at low operating temperatures, even showing potential for room temperature operation, with excellent sensitivity even in the presence of humidity.

Furthermore, increasing the operating temperature and loading the octahedra with Pt, result in the quenching of the response to NO₂ and in an increase in the response towards H₂. In this way, one can make the sensor more selective to reducing gases such as H₂. However, in this case the presence of ambient humidity negatively influences the response of the sensor.

As a consequence, our nanomaterial can be made selective to oxidizing or reducing gases by varying the operating temperature and by metal loading.

These significant differences revealed by this study suggest that engineering the morphology and the crystallinity of the material can be really useful and need further research, since it may become an effective strategy for enhancing the sensitivity and selectivity of In₂O₃ sensors.

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